PATENT SPECIFICATION

(11) 1 516 351

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(33) United States of America (US)

(44) Complete Specification published 5 July 1978

(51) INT CL³ C08G 59/68; G03C 1/71//B32B 17/04, 17/06, 27/04, 27/26, 27/38

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(72) Inventor JAMES VINCENT CRIVELLO

(54) IMPROVEMENTS IN CURABLE EFOXIDE COMPOSITIONS

(22) Filed 16 April 1975

(71) We, GENERAL ELECTRIC COMPANY, a corporation organized and existing under the laws of the State of New York, United States of America, of 1 River Road, Schenectady 12305, State of New York, United States of America, do hereby declare the invention, for which we pray that a patent may be granted to us, and the method by which it is to be performed, to be particularly described in and by the following statement:—

The present invention relates to curable compositions and in particular epoxy resin compositions which can be cured by exposure to radiant energy.

PATENTS ACT 1949

SPECIFICATION NO 1516351

The following amendments were allowed under Section 29 on 28 August 1981:

Page 4, line 37, after catalyst. insert Lewis Acid means protonic as well as non-protonic acid

THE PATENT OFFICE 6 October 1981

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25	these aromatic diazonium sans are capable of releasing, in sim, a zero resolution catalyst which can initiate the rapid polymerization of the epoxy resin. However, even though these one package epoxy resin mixtures can provide fast curing compositions, a stabilizer must be used to minimise cure in the dark during	25
30	storage of these mixtures. Despite these measures, gellation of the mixture can occur even in the absence of light. In addition, nitrogen is released during UV-cure, which can result in film imperfections. Diazonium salts are generally thermally unstable, rendering the use of such materials hazardous because of the possibility of run-away decomposition.	30
35	Accordingly the present invention provides a curable composition comprising (A) a monoepoxide or an epoxy resin or a mixture thereof polymerizable to a higher molecular weight state, and (B) a radiation sensitive aromatic halonium salt in an amount capable of effecting the cure of (A) by release of a Lewis Acid catalyst when exposed to radiant	35
40	energy. A mixture of aromatic halonium salt can be used as a Lewis Acid source if desired. The present invention also provides a method for effecting the cationic polymerization of epoxy material which comprises	40
	(1) forming a mixture of a monoepoxide or an epoxy resin or a mixture thereof and a radiation sensitive aromatic halonium salt capable of effecting the cure	



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(54) IMPROVEMENTS IN CURABLE EPOXIDE COMPOSITIONS

We, GENERAL ELECTRIC COMPANY, a corporation organized and existing under the laws of the State of New York, United States of America, of 1 River Road, Schenectady 12305, State of New York, United States of America, do hereby declare the invention, for which we pray that a patent may be granted to us, and the method by which it is to be performed, to be particularly described in and by the following statement:-

The present invention relates to curable compositions and in particular epoxy

resin compositions which can be cured by exposure to radiant energy.

Epoxy resins have generally been employed in a variety of applications requiring high performance materials. Cure of an epoxy resin can generally be achieved by two package systems based on the incorporation into the resin of active amine containing compounds or carboxylic acid anhydrides. These systems require thorough mixing of the ingredients; in addition, cure time can be several

Another catalyst which can be used to cure epoxy resins as "one package" systems is based on the employment of a Lewis Acid catalyst in the form of an amine complex such as boron trifluoride-monoethylamine. The Lewis Acid is released on heating; cure takes place within 1 to 8 hours and can require a temperature of 160°C. and higher. As a result, these one package epoxy compositions cannot be employed to coat heat sensitive devices such as delicate electronic components. Nor can epoxy monomers having low boiling points be

used due to the resulting losses to evaporation during cure.

As shown by Schlesinger, U.S. Patent 3,703,296, certain photosensitive aromatic diazonium salts can be employed to cure epoxy resins. When photolyzed, these aromatic diazonium salts are capable of releasing, in situ, a Lewis Acid catalyst which can initiate the rapid polymerization of the epoxy resin. However, even though these one package epoxy resin mixtures can provide fast curing compositions, a stabilizer must be used to minimise cure in the dark during storage of these mixtures. Despite these measures, gellation of the mixture can occur even in the absence of light. In addition, nitrogen is released during UVcure, which can result in film imperfections. Diazonium salts are generally thermally unstable, rendering the use of such materials hazardous because of the possibility of run-away decomposition.

Accordingly the present invention provides a curable composition comprising (A) a monoepoxide or an epoxy resin or a mixture thereof polymerizable to a

higher molecular weight state, and
(B) a radiation sensitive aromatic halonium salt in an amount capable of effecting the cure of (A) by release of a Lewis Acid catalyst when exposed to radiant

A mixture of aromatic halonium salt can be used as a Lewis Acid source if desired.

The present invention also provides a method for effecting the cationic polymerization of epoxy material which comprises

(1) forming a mixture of a monoepoxide or an epoxy resin or a mixture thereof and a radiation sensitive aromatic halonium salt capable of effecting the cure





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of such mixture by the release of a Lewis Acid catalyst when exposed to radiant energy, and

(2) exposing said mixture to radiant energy to effect the cure of the epoxy material.

The present invention is based on the discovery that certain radiation sensitive aromatic halonium salts, such as compounds of the formula,

can be incorporated into epoxy resins to provide one-package radiation curable compositions which do not require a stabilizer to minimise cure at ambient temperatures during the shelf period, and are free of all the aforementioned disadvantages of the above described diazonium salt compositions.

Included among the above shown radiation sensitive aromatic halonium salts which can be used to make the curable compositions of the present invention are compounds of the formula

15 (I)
$$\left[\begin{array}{c} (R)_a (R^1)_b x \\ \end{array} \right]_c^+ \left[\begin{array}{c} MQ_d \end{array} \right]^{-(d-e)}$$

where R is a monovalent aromatic organic radical, R^1 is a divalent aromatic organic radical, X is a halogen radical such as I, Br and Cl, M is a metal or metalloid and Q is a halogen radical such as Cl, F, Br or I, a is 0, and b is 1 or a is 2 and b is 0,

c=3-e 20 e-valence of M and is an integer equal to 2 to 7 inclusive, and d is >e and is an integer having a value up to 8.

Radicals included by R can be the same or different, aromatic carbocyclic or heterocyclic radical having from 6 to 20 carbon atoms, which can be substituted with from 1 to 4 monovalent radicals selected from, for example, $C_{(1-6)}$ alkoxy, $C_{(1-6)}$ alkyl, nitro and chloro, R is more particularly, phenyl, chlorophenyl, nitrophenyl, methoxyphenyl or pyridyl. Radicals included by R^1 are divalent radicals such as

Metal or metalloids included by M of formula I are transition metals such as Sb, Fe, Sn, Bi, Al, Ga, In, Ti, Zr, Sc, V, Cr, Mn, Cs, rare earth elements such as the lanthanides, for example, Cd, Pr and Nd, actinides, such as Th, Pa, U and Np and metalloids such as B, P, and As. Complex anions included by MQ₄-(d-e) are, for example, BF₄-, PF₅-, AsF₅-, SbF₆-, FeCl₄-, SnCl₅-, SbCl₅-, BiCl₅-.

Halonium salts included by formula I are, for example, 30

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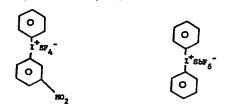
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1,516,351

In one aspect the present invention the salts for use as photoinitiators can be of the formula:

$$\left[\begin{array}{ccc} (R)_a & (R^i)_b & X \end{array}\right] \ ^+ \ \left[\begin{array}{ccc} MF_4 \end{array}\right] \ ^-$$

where M is P, As or Sb, R is a monovalent aromatic organic radical, R is a divalent aromatic organic radical, X is a halogen radical, a is 0, 1 or 2, b is 0 or 1, and a + b is equal to 2 or the valence of X. These salts are described and claimed in

and a + b is equal to 2 or the valence of A. I ness saits are described and claimed in our Patent Application No. 498/78 (Serial No. 1,516,352).

The halonium salts of formula I are well known and can be made by the procedures described by O.A. Ptitsyna, M.E. Pudecva, et al, Dokl, Adad. Nauk, SSSR, 163 383 (1965); Dokl., Chem., 163 671 (1965). F. Marshall Beringer, M. Drexler, E. M. Gindler, etc. J. Am. Chem. Soc., 75 2705 (1953).

The term "epoxy resin" as utilised in the description of the curable

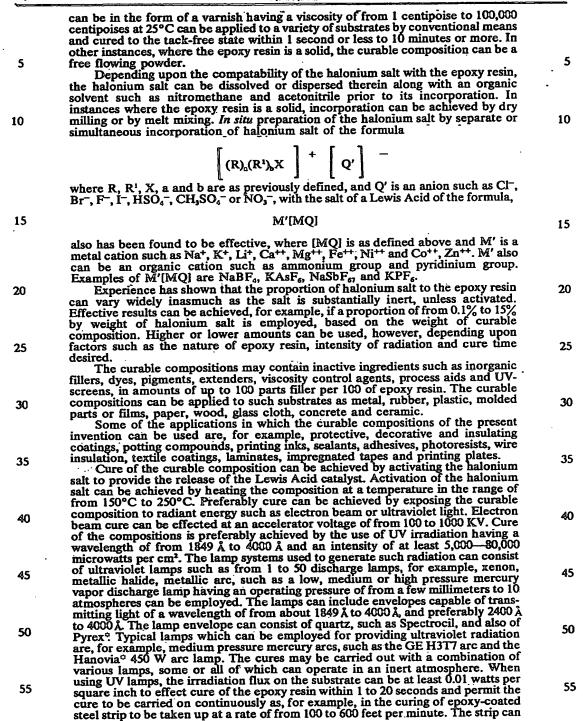
The term "epoxy resin" as utilised in the description of the curable compositions of the present invention, includes any monomeric, dimeric or oligomeric or polymeric epoxy material containing one or a plurality of epoxy functional groups. For example, those resins which result from the reaction of bisphenol-A (4,4'-isopropylidenediphenol) and epichlorohydrin, or by the reaction of low molecular weight phenol-formaldehyde resins (Novolak resins) with epichlorohydrin, can be used alone or in combination with an epoxy containing compound as a reactive diluent. Such diluents as phenyl glycidyl ether, 4-vinyl-cyclohexene dioxide, limonene dioxide, 1,2-cyclohexene oxide, glycidyl acrylate, glycidyl methacrylate, styrene oxide and allyl glycidyl ether may be added as viscosity modifying agents.

viscosity modifying agents.

In addition, the range of these compounds can be extended to include in addition. Examples of polymeric materials containing terminal or pendant epoxy groups. Examples of these compounds are vinyl copolymers containing glycidyl acrylate or methacrylate as one of the comonomers. Other classes of epoxy containing polymers amenable to cure using the above catalysts are epoxy-siloxane resins, epoxy-polyurethanes and epoxy-polyesters. Such polymers usually have epoxy functional groups at the ends of their chains. Epoxy-siloxane resins and method for making are more particularly shown by E. P. Plueddemann and G. Fanger, J. Am. Chem. Soc. 81 632—5 (1959). As described in the literature, epoxy resins can also be modified in a number of standard ways such as reactions with amines, carboxylic acids, thiols, phenols, alcohols, etc. as shown in U.S. patents 2,935,488; 3,235,620; 3,369,055; 3,379,653; 3,398,211; 3,403,199; 3,563,850; 3,567,797; and 3,677,995. Further examples of epoxy resins which can be used are shown in the Encyclopedia of Polymer Science and Technology, Vol. 6, 1967, Interscience

Publishers, New York, pp 209—271.

The curable compositions of the present invention can be made by blending the epoxy resin, which hereinafter will signify epoxy monomer, epoxy prepolymer, oxirane containing organic polymers or a mixture thereof, with an effective amount of the halonium salt. The resulting curable composition which



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EXAMPLES 4-9.

Several curable compositions were prepared in accordance with the procedure shown in Example 1 using 4-vinylcyclohexene dioxide and about 3% by weight of the halonium salt. Various cure times were experienced when the compositions were applied onto a glass substrate and cured at a distance of four inches from a GE H317-lamp. The following shows the halonium salt used, its m.p. and the cure times.

Halonium Salt

Examples	Cation	Anion	Мр. (°С)	Cure Time* (min.)
4	(o) r⁺ —(o)	BF ₄	136	0.5
. 5	(o)-1* -(o)	PF ₆	138–141	0.5
6	(o)- r*(o)	SbF ₆	57—58 imp.	0.5
7	O 1+ —O OCH3	BF ₄	86–100	1
8	ca, 0 r - 0 ca,	BF ₄ -	95—100	0.5
9		BF ₄ -	133–135	1

10 * Time required to cure a 2 mil film containing 3% of the salt at a distance of 4 inches from a G.E. H3T7 lamp.

EXAMPLE 10.

To 10 g limonene dioxide were added 0.32 g diphenyliodonium chloride and 0.21 g sodium hexafluoroarsenate. This mixture was heated for 20 minutes at 50°C to achieve metathesis. The salts were allowed to settle and the clear supernatent liquid was drawn off. The sensitized epoxy compound was applied to a steel strip to a thickness of 2 mil and exposed to UV light as described above. Cure took place in 20 seconds. A tough film having good adhesion to the steel plate was obtained 30 seconds. A tough film having good adhesion to the steel plate was obtained.

EXAMPLE 11. Three parts of diphenyliodonium fluoroborate were ground to a fine powder

7	1,516,351	7
5	and tumbled for 30 minutes with 97 parts of Reichhold Epotuf ^o 37—834, a bisphenol A epoxy powder coating resin. The powder blend was then electrostatically sprayed onto 3 in × 6 in steel samples to form a 2 mil coating using a GEMA model 171 spray gun. Subsequently, the samples were heated briefly to 150°C to fuse the powder and then exposed while hot to a GE H3T7 medium pressure mercury are lamp at a distance of 3 inches. Cured samples were obtained after 30 seconds exposure.	5
10	EXAMPLE 12. Three parts by weight of di-p-tolyl iodonium fluoroborate were added to 97 parts of (3,4-epoxycyclohexyl)-methyl-3,4-epoxycyclohexanecarboxylate. The epoxy resin was then used to impregnate a 1 inch woven glass tape. After winding two turns of the tape onto a 4 in diameter drum, the tape was cured to a rigid glass band by rotating the drum under a GE H3T7 lamp at a distance of 4 inches for 2 minutes. The banding tapes thus prepared can be used as restraining bands in	10
15	motors and generators. The above resin was used to impregnate woven glass cloth. Two 6 in \times 6 in squares of the glass cloth were stacked on top of one another and cured for 1 minute on each side. A rigid composite was obtained which is useful for circuit	15
20	board applications. A portion of the above mixture was used to impregnate glass roving. The treated glass was then wound onto a 3 in dia. drum to a thickness of about 5 mils. The drum was then rotated beneath a GE H3T7 lamp at a distance of 3 inches for 5 minutes. A measurement of the intensity of the lamp showed that it was	20
25	approximately 200 watts/sq. inch. When the cured winding was removed from the drum, it was rigid and fully cured. A typical use for such a cured winding is as a spool for electrically conducting wire.	25
30	EXAMPLE 13. A mixture was prepared consisting of 14.5 g (0.25 mole) glycidyl allyl ether, 10 mg. t-butyl-catechol, and 3 drops chloroplatinic acid in octyl alcohol. The reaction mixture was heated to 50°C in a water bath and then 13.0 g of a polydimethyl siloxane resin containing 0.89% by weight Si-H groups was added dropwise by means of a dropping funnel. Immediate exothermic reaction took place with the temperature rising to 65°C. Reaction proceeded smoothly at this temperature	30
35	giving a clear resin. Three parts by weight of 4-methoxydiphenyliodonium fluoroborate dissolved in a small amount of methylene chloride was added to 97 parts of the above silicone epoxy resin. A 2 mil film of the sensitized resin was drawn on a steel plate and then exposed to UV light from a GE H3T7 lamp at a distance of six inches. The film was tack-free within 10—15 seconds. A small amount of silica was added to the sensitized resin to produce a thixotropic mixture and the resin cured as described previously. A tough, rubbery coating resulted.	35 40
45	EXAMPLE 14. A solution of 3 parts of 4-methoxydiphenyliodonium fluoroborate dissolved in 20 parts of 4-vinyl-cyclohexene dioxide was added to 80 parts of a glycidyl methacrylatemethyl methacrylate copolymer having a molecular weight of 8,500 and a glycidyl acrylate content of 5% by weight. This mixture was mixed by rolling it in a glass bottle on a ball mill overnight. The viscous solution was knife coated onto a glass plate to give a 2 mil film which when irradiated at a distance of six inches from a FE H3T7 lamp, gave a clear hard coating in 10 seconds. The film was highly crosslinked and insoluble in all common solvents.	45 50
55	EXAMPLE 15. Three parts of diphenyliodonium hexafluoroarsenate were dissolved in 6.7 parts of methylene chloride and the solution added to 97 parts glycidyl acrylate. A 3 part aliquot of this highly fluid mixture was placed in an aluminum cup and then exposed to the ultraviolet irradiation of a H3T7 lamp using a water filter. The cure time was 15 seconds. Subsequent analysis showed that the conversion to polymer was greater than 95%. A hard glossy resin was obtained.	55

EXAMPLE 16.
A blend was prepared using equal parts of 4-vinyl-cyclohexene dioxide and

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A mixture was prepared consisting of by weight 67% of a novolak-epoxy resin having an epoxy equivalent weight of 172—178, 33% 4-vinylcyclohexene dioxide, 0.5% of a surface active agent, and 1% diphenyliodonium hexafluoroarsenate. The mixture was applied as a 0.1 mil film to 3 in × 6 in steel plates. The treated plates were exposed for 20 seconds at a distance of 4 inches from a GE H3T7 medium pressure mercury arc lamp. Panels were subsequently immersed for 5 hrs. at room temperature in methylene chloride; others were immersed for 4 hours in acetone. In all cases, no visible signs of attack on the coating by these agents were observed. The panels were baked for 1 hour at 160°C, then tests were run separately in boiling 5% KOH solution for 30 minutes and in boiling distilled water for 4 hours. At the end of these tests, the coatings were intact and showed no signs of

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degradation.

Although the above examples are limited to only a few of the very many curable compositions and uses thereof which are included within the scope of the present invention, it should be understood that the present invention is intended to cover a much broader class of curable compositions and uses thereof. Those

1,516,351 9 9 skilled in the art would also know that the curable compositions also cover the use of halonium polymers containing halonium functionality as part of the polymer backbone or in the pendant position. WHAT WE CLAIM IS:-5 1. A curable composition comprising 5 (A) a monoepoxide, an epoxy resin or a mixture thereof polymerizable to a higher molecular weight state, and (B) a radiation sensitive aromatic halonium salt in an amount capable of effecting the cure of (A) by release of a Lewis Acid catalyst when exposed to radiant 10 energy. 10 2. A composition in accordance with claim 1, where the aromatic halonium salt is a diphenliodonium salt. 3. A composition in accordance with claim 2, where the complex anion of the diphenyliodonium salt is a tetrafluoroborate. 15 4. A composition in accordance with claim 2, where aromatic iodonium salt is 15 diphenyliodonium hexafluorophosphate. 5. A composition in accordance with claim 2, where the complex anion of the diphenyliodonium salt is a hexafluoroantimonate. 6. A composition in accordance with claim 2, where the complex anion of the 20 diphenyliodonium salt is a hexasluoroarsonate. 20 7. A composition in accordance with any one of Claims 1-6 where the aromatic halonium salt is prepared in situ. A composition in accordance with any one of Claims 1—7 where a mixture of aromatic halonium salts are employed as the Lewis Acid source. 9. A composition in accordance with any one of Claims 1 to 8 in the form of a 25 25 fluid at room temperature. 10. A composition in accordance with any one of Claims 1 to 8 in the form of a free-flowing powder. 11. A printing ink of/or containing a composition in accordance with any one of Claims 1-10. 30 30 12. A method for effecting the cationic polymerization of epoxy material which comprises (1) forming a mixture of a monoepoxide, an epoxy resin or a mixture thereof and a radiation sensitive aromatic halonium salt in an amount capable of effecting the cure of such mixture by the release of a Lewis Acid catalyst when exposed 35 35 to radiant energy, and (2) exposing said mixture to radiant energy to effect the cure of the epoxy resin. 13. A method in accordance with Claim 12, where the cure is effected with ultraviolet light. 14. A method in accordance with Claim 12, where the cure is effected with 40 40 electron beam. 15. A method in accordance with any of Claims 12—14 where the cured expoy resin is subsequently heat treated. 16. A method in accordance with any one of Claims 12 to 15, where the mixture is applied to a substrate prior to cure 45 45 17. A method in accordance with Claim 16, where the mixture is applied to the substrate by use of an organic solvent. 18. A method in accordance with Claim 16 or 17, where a mask is employed to generate a photo image. 19. A method as claimed in any one of claims 12 to 18 wherein the salt has the 50 50 formula $(R)_a (R^1)_b X$

where M is P, As or Sb, R is a monovalent aromatic organic radical, R^1 is a divalent aromatic organic radical, X is a halogen radical, a is 0, and b is 1 or a is 2 and b is 0.

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20. A method as claimed in Claim 19 where M is P and X is I.

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21. A method as claimed in Claim 19 wherein the salt has the formula:

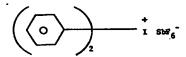


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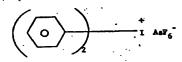
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22. A method as claimed in Claim 19 wherein the salt has the formula:



23. A method as claimed in Claim 19 wherein the salt has the formula:



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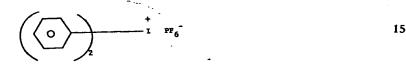
24. A curable composition comprising:
(A) a monoepoxide, an epoxy resin or a mixture thereof polymerizable to a higher molecular weight state, and

(B) a radiation sensitive salt having the formula

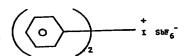
$$(R)_a (R_1)_b X + MF_6 -$$

10 where M is P, As or Sb, R is a monovalent aromatic organic radical, R1 is a divalent aromatic organic radical, X is a halogen radical, a is 0 and b is 1, or a is 2 and b is 0. 25. A composition as claimed in claim 24 where M is P and X is I.

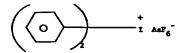
26. A composition as claimed in claim 24 where the salt has the formula:



27. A composition as claimed in claim 24 where the salt has the formula:



28. A composition as claimed in claim 24 wherein the salt has the formula:



20 29. A curable composition as claimed in claim 1 substantially as hereinbefore described in any one of the examples.

30. A composition as claimed in any one of claims 1 to 10 and 24 to 29 when cured.

31. A method of effecting the cationic polymerization of epoxy resin as claimed in claim 12 substantially as hereinbefore described in any one of the 25 25

PAUL M. TURNER, Agent for the Applicants.

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